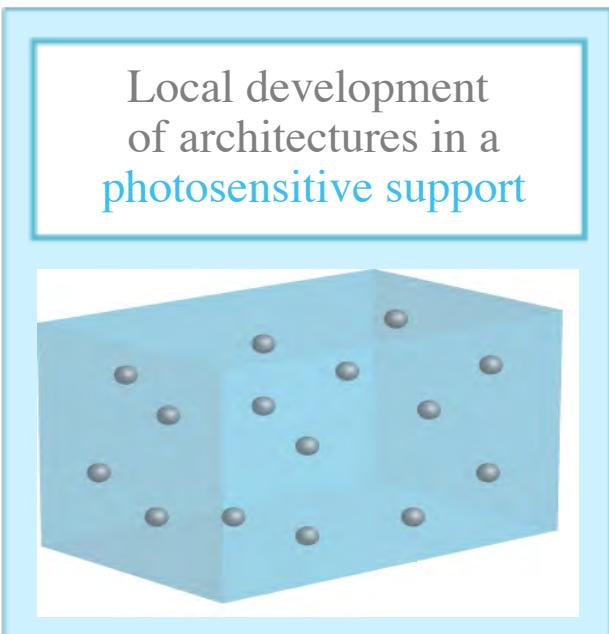
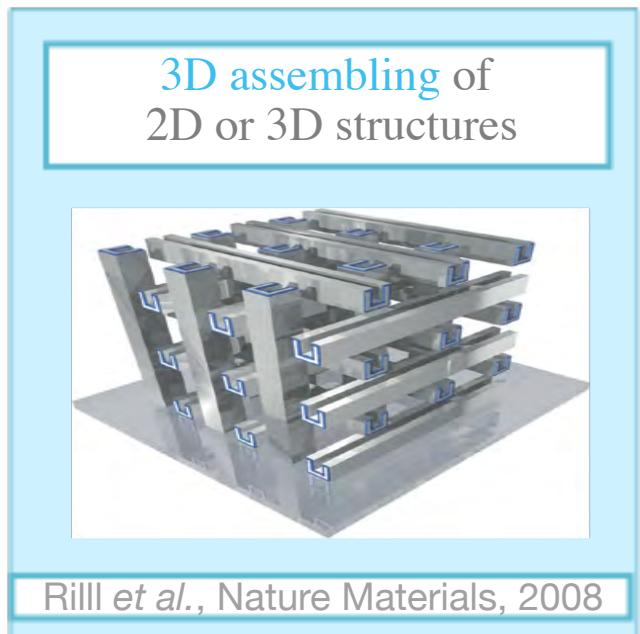
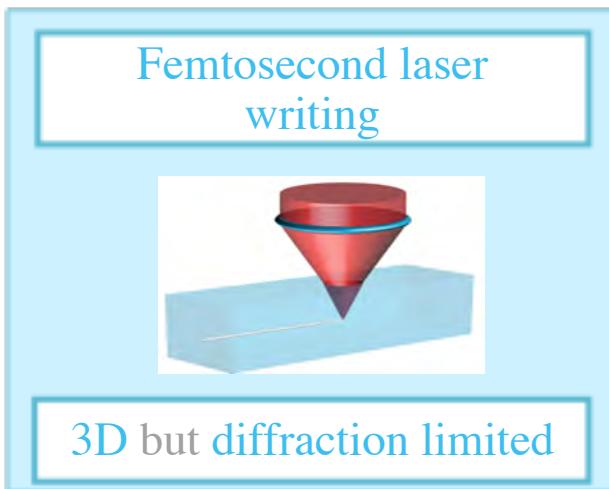
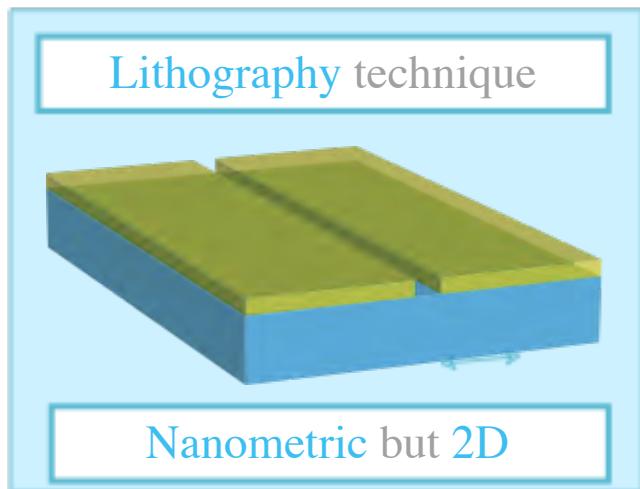


Structuration par LASER des Propriétés Optiques Linéaire et Non-Linéaire des Verres

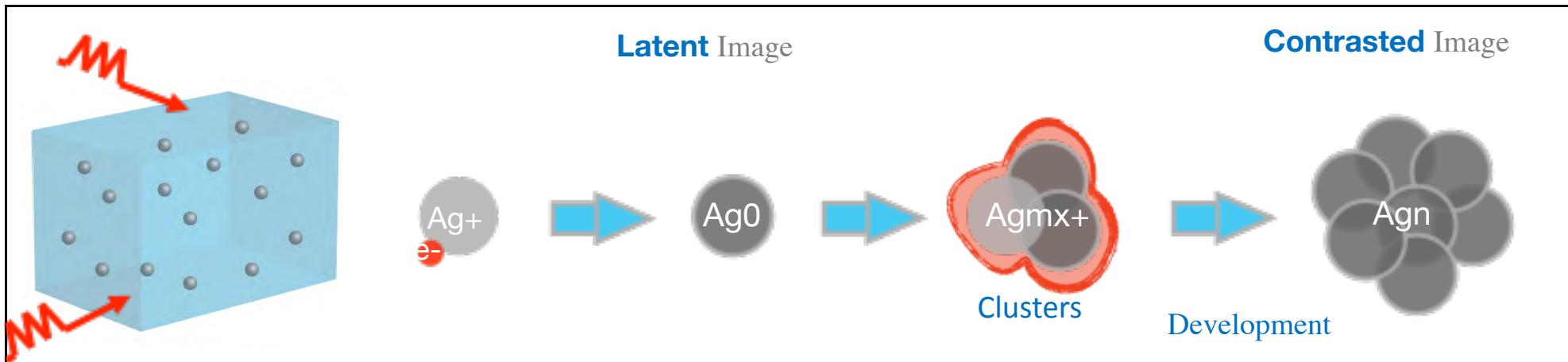
Y. PETIT E.J. Lee, K. Mishchik, J.-C. Desmoulin, N. Varkentina,
E. Brasselet, I. Manek-Hönninger, Marie Vangheluwe, Alain Abou Khalil
T. Cardinal, & L. Canioni

I.a. Towards new 3D photonic structures

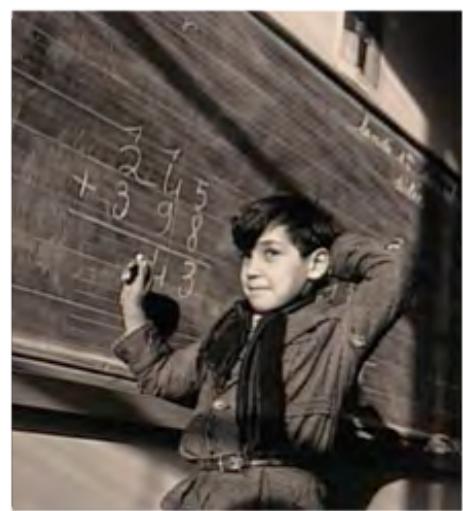


- Evolution to nano-scale structures with multi-scale 3D architectures
- New elementary optical bricks at smaller dimensions
 - new shapes
- 3D architectures with versatile DLW with multi-functionalities

Photosensitive materials: Phosphate glass

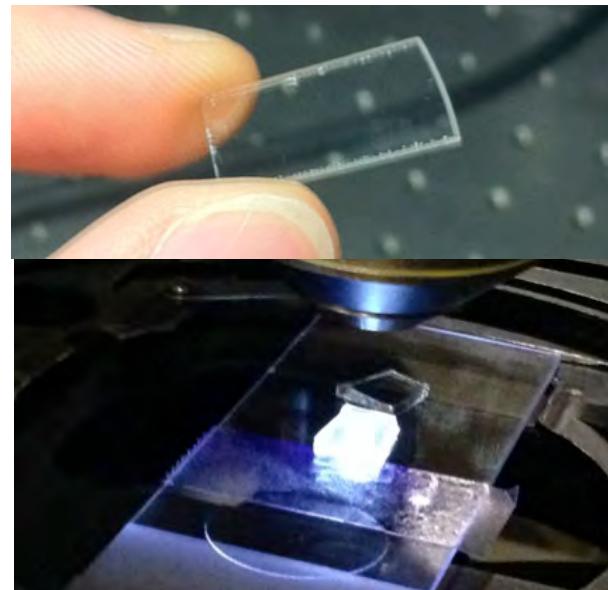


Photographic Film



Doisneau, *Mathématiques*, 1941

Glass Femto-photo-luminescent: **FPL**



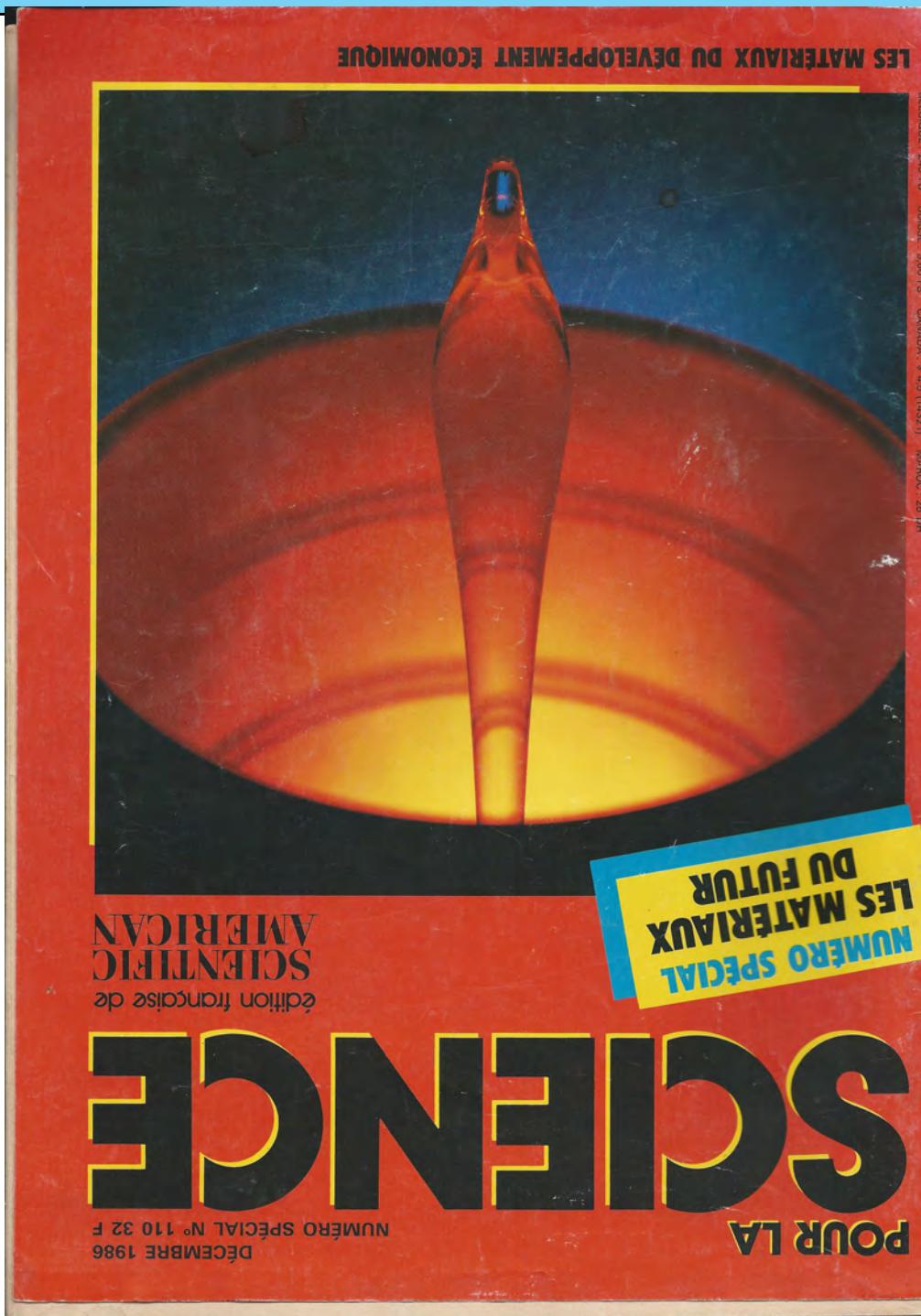
P₂O₅ /ZnO / Ag₂O/Ga

Photosensitive Glass

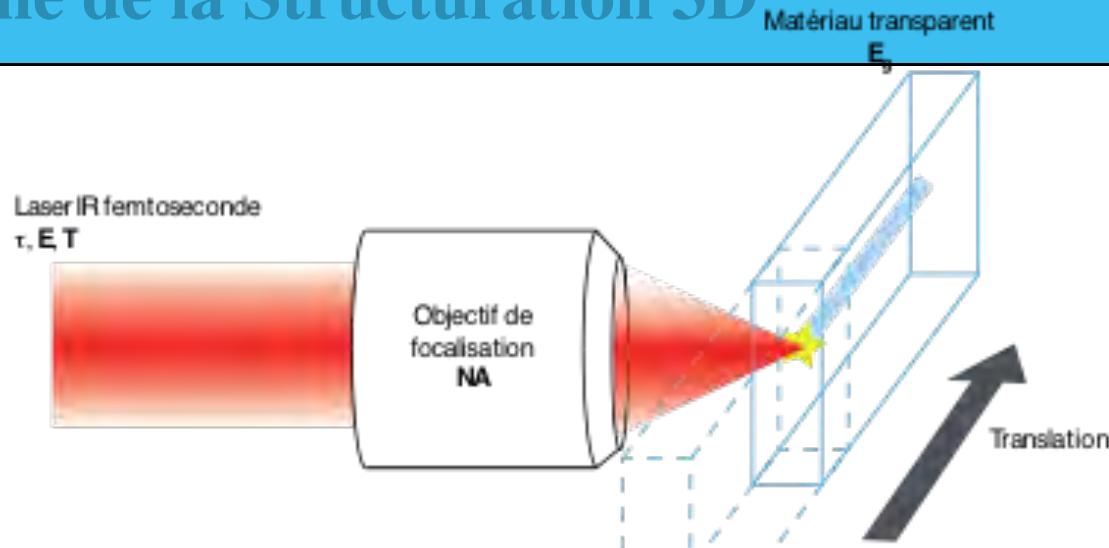


Stookey, Ind. Eng. Chem., 1949

Le verre? Le matériau du futur?

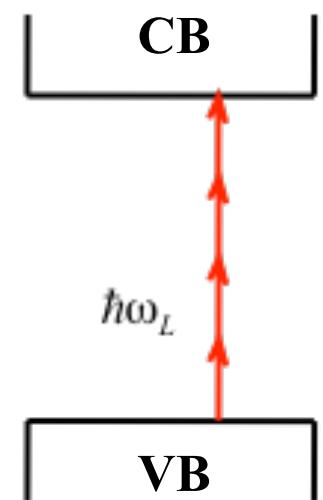
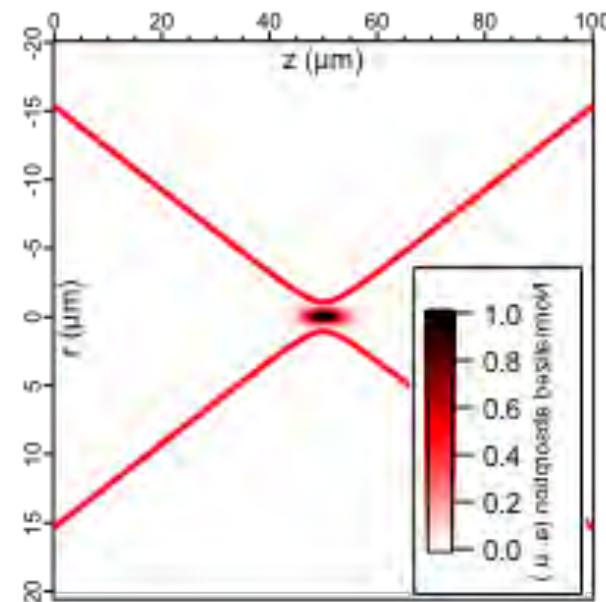
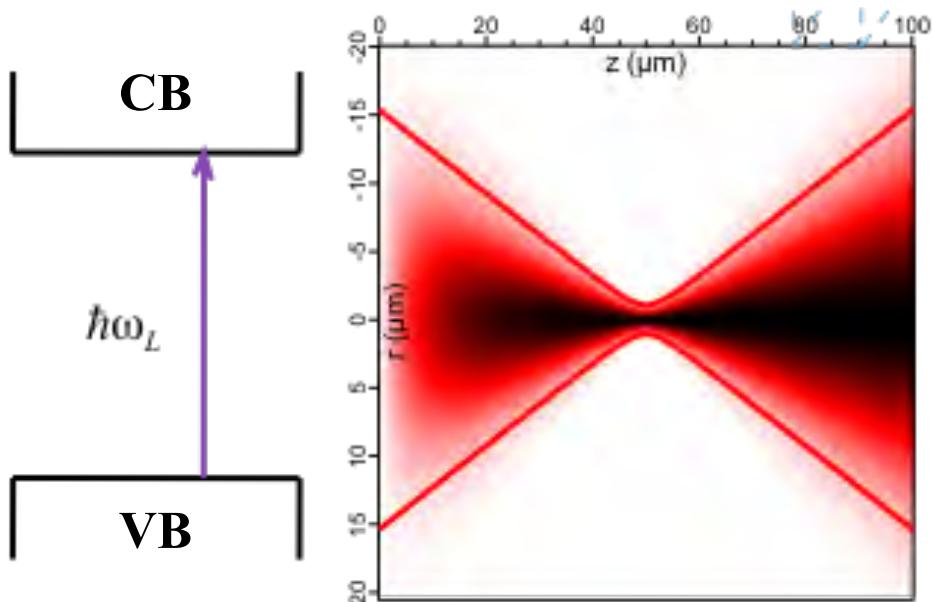


Origine de la Structuration 3D



Clef: absorption non-linéaire du laser femtoseconde

Principe de structuration 3D



Dépot d'énergie dans un semi conducteur suite à une absorption linéaire gauche et non-linéaire à droite



Photo-ionization (multiphoton absorption and/or tunneling ionization) (after 1 fs)



Avalanche ionization (after 50 fs)



Thermalization of the electrons (after 100 fs)



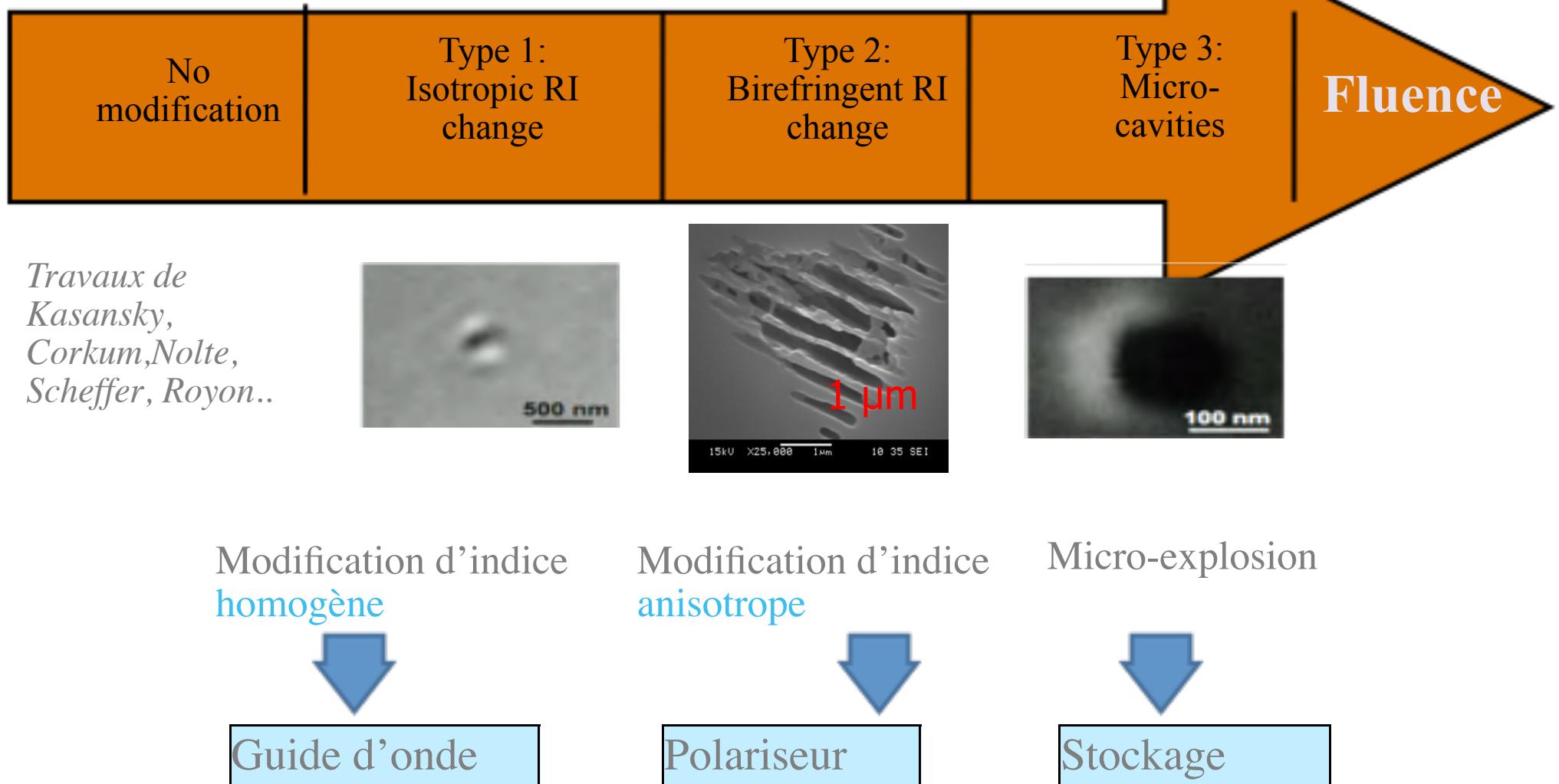
Energy transfer electrons → lattice (after 1 ps)

Thermodynamic processes (thermal diffusion, fusion and/or explosion) (after 10 ps)



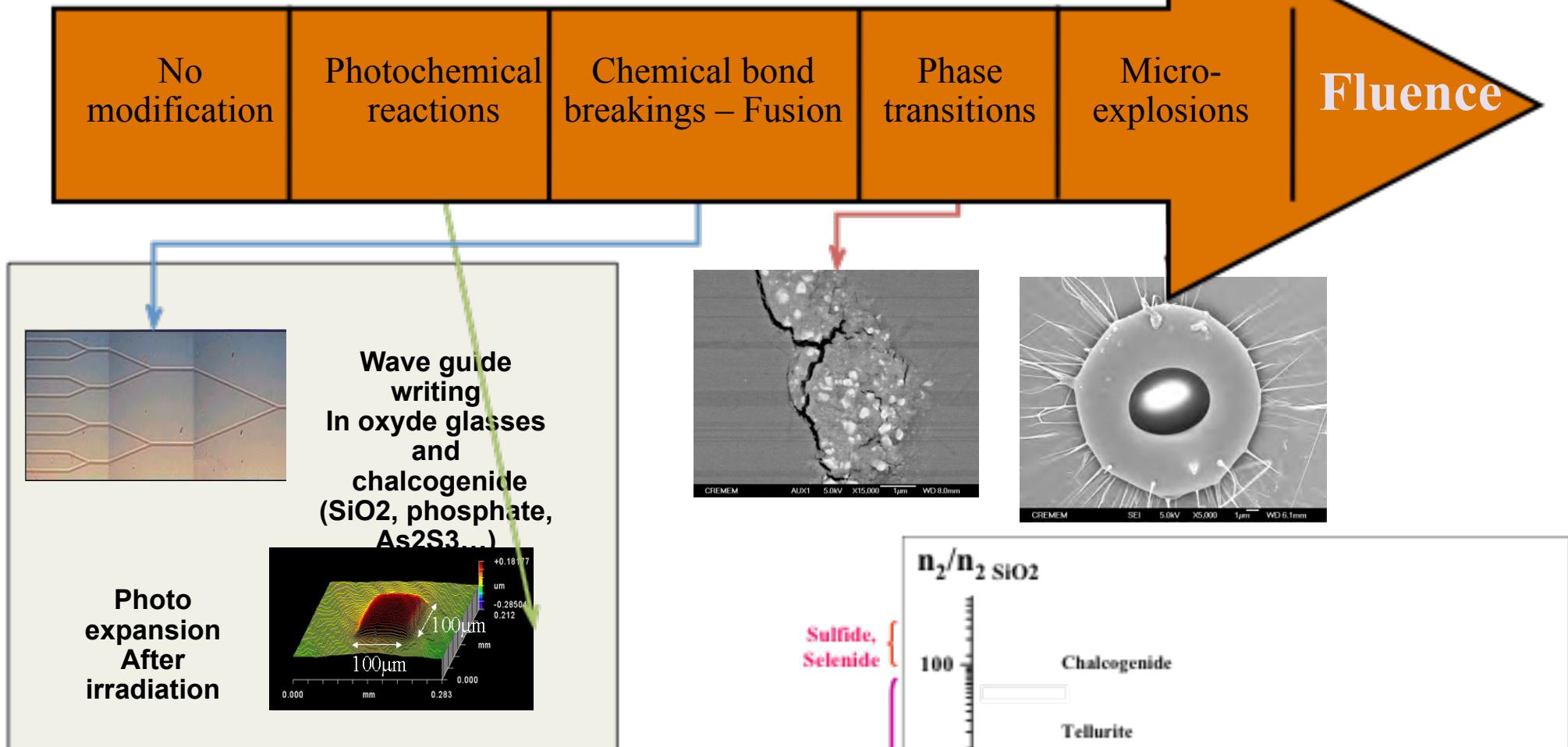
Photochemical processes (chemical reactions and/or phase transitions) (after 1 ns)



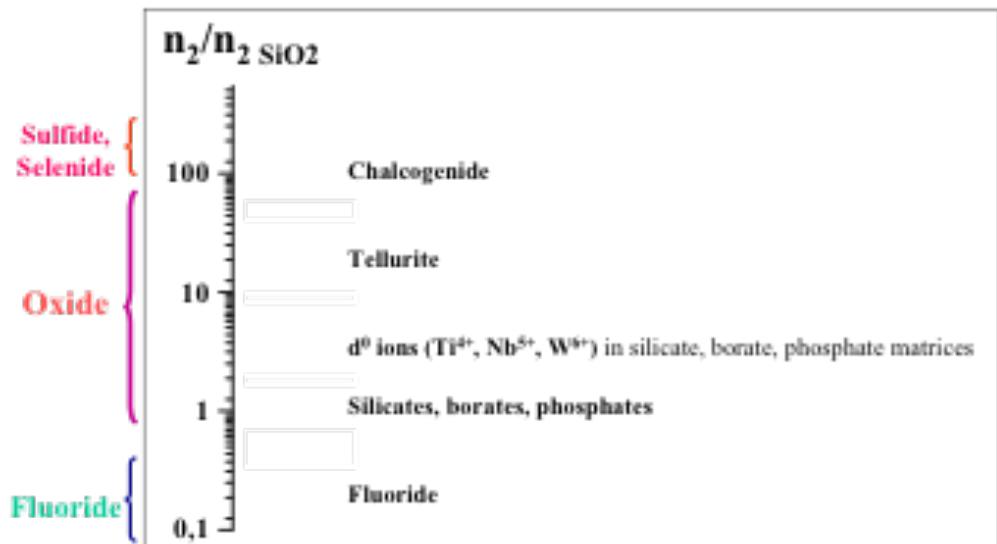


La structuration dépend fortement de la fluence (J/cm²)

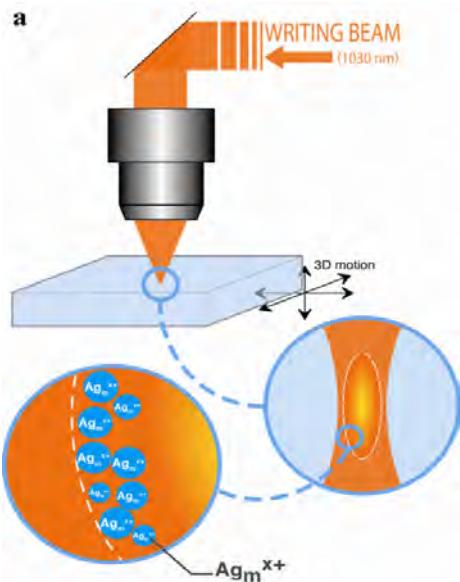
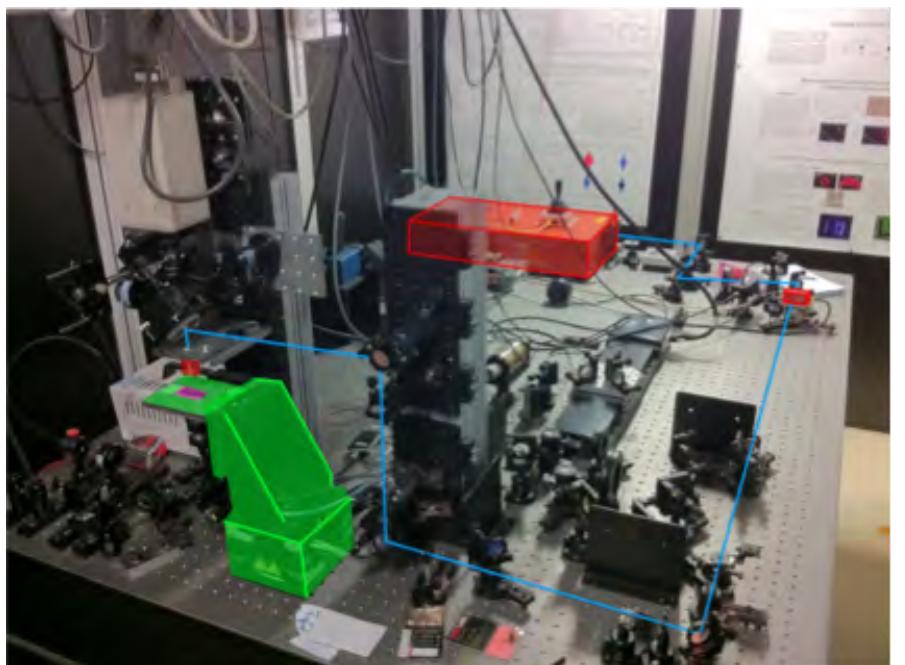
Exemple de structuration de matériaux vitreux



Les grandes familles de verre et l'échelle des non-linéarités



1. **Caractéristiques de l'inscription directe laser**
2. **La photo-excitation**
3. **Effets d'accumulation, diffusion, thermo-élastiques**
4. **Propriétés non-linéaire second ordre**
5. **Post Traitement thermique**



Ryon et al., Adv. Mat.
DOI 10.1002/adma.201002413 (2010).

Duration 390fs @1030nm
NA: 0.2 → 1.3
En: 0 → 400 nJ
Freq : 0 → 10 Mhz

Femtosecond
laser

High repetition rate

Pulse energy,
repetition rate
and/or number of
pulses adjustments

White light or
UV illumination

SHG

THG

Sample in oven
(20@C → 400°C)

